

Patent CIT.PAU.01

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF:

SCHERER ET.AL.

**SERIAL NO.: 10/068,283** 

FILED: FEB. 5, 2002

FOR: DRY ETCHING AND MIRROR

DEPOSITION PROCESSES FOR SILICONE ELASTOMER

**Examiner: R. McDonald** 

**Group Art Unit: 1753** 

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TC 1700

## **AMENDMENT**

Hon. Commissioner of Patents and Trademarks Washington DC 20231

Sir:

In reply to the Office Action mailed June 30, 2003, please enter the following amendments and consider the following remarks.

Claims 1-20 were original in the application. Claims 2-13 have been indicated as allowable. Claim 1 has been amended. Claims 16-20 were withdrawn. Claims 21-25 are new. Therefore, claims 1-15 and 21-25 are submitted for examination on the merits in amended form.

A check for the appropriate fee for excess claims for a small entity is included. The Office is also authorized to charge all fees under 37 CFR § 1.17, or all required extension of time fees or any deficit and credit any surplus in such fees to our deposit account #01-1960.

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